



Single bounce ellipsoidal glass moncapillary condenser for X-ray nano-imaging

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ABSTRACT

A single bounce ellipsoidal glass moncapillary was designed and fabricated and its performance was measured by both an optical measurement and an X-ray test. This moncapillary had a slope error of 17 μrad . The images of the focal spot and the far-field pattern recorded by a CCD detector showed that this fabricated moncapillary had high quality and satisfied the requirement of the designed data for X-ray nano-imaging.

1. Introduction

Today, X-ray nano-imaging has a wide range of applications in many fields such as energy, environment, food, medicine, biology, etc. One of the key aspects of this technology is how to focus the X-ray [1–12]. In full-field X-ray nano-imaging, the most commonly used condenser devices are zone plates and ellipsoidal moncapillaries. However, zone plates have low diffraction efficiency and limitations in bandwidth [13,14]. Moreover, their fabrication limits their aperture size. Accordingly, zone plates have a restricted range of application, especially in the high-energy range. In contrast, the transmission efficiency of ellipsoidal glass moncapillary X-ray focusing optics is higher than that of zone plates. Therefore, ellipsoidal moncapillaries are generally adopted as focusing lenses in full-field transmission X-ray nano-imaging. Consequently, much attention has been focused on the development of ellipsoidal moncapillaries [15–17]. There are two ways to fabricate such moncapillaries: the mold and drawing tower methods. A chemical treatment is necessary in the post-production of the mold procedure. This treatment may affect the roughness of the inner surface in the moncapillary and consequently influence the quality of the optics. However, the drawing-tower method does not need such a chemical pretreatment. Therefore, many researchers use the drawing tower method to fabricate ellipsoidal moncapillaries.

In X-ray nano-imaging, the requirement on the slope error of the

monocapillary is very strict [18], which means that the fabrication technology of the moncapillary has to be very precise. In this paper, a new constant-temperature furnace was used to draw single-bounce ellipsoidal glass moncapillaries for use as X-ray focusing optics. We will also discuss the performance of the moncapillaries.

2. Methods

Table 1 provides the parameters of an ideal moncapillary for X-ray nano-imaging. To meet these requirements, we used silicate glass as our raw material. In the process of drawing the moncapillary, we applied a software-based procedure to control the drawing tower with a constant temperature field. This constant temperature furnace was used to heat a small-section uniform tube. Then, by changing relevant parameters, we can make the ellipsoidal moncapillary. After the fabrication of the moncapillary, we need to know whether the fabricated optics satisfies the design requirement. The slope error measured in $\mu\text{rad rms}$ is one way to address this, because it represents the deviation between the ideal and real shapes. The slope error of the moncapillary would lead to a blur in the focal plane and accordingly affect its focusing quality [13]. Therefore, we could change the drawing parameters based on the slope error to improve the quality of the moncapillary. To meet these requirements, we applied an optical measurement to evaluate the diameter and straightness errors to

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Table 1
Designed parameters of the ellipsoidal moncapillary.

Parameter	Ellipsoidal moncapillary
Energy (keV) (Cu-target X-ray tube)	8.04
Length(mm)	32.424
Receiving aperture (mm)	0.636
Exit aperture (mm)	0.622
The distance between the center of moncapillary and the X-ray source (mm)	291.202
The distance between the center of moncapillary and focal spot (mm)	208.798
Major semi axis (mm)	250.000
Minor semi axis (mm)	0.320
Working distance (mm)	192.586
Compression ratio	0.72

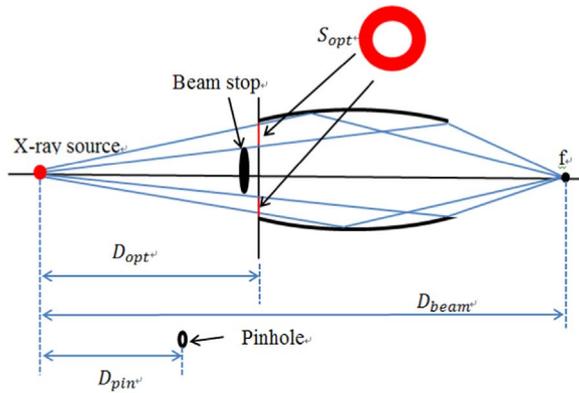


Fig. 1. The sketch of measuring the transmission efficiency and the gain in power density of moncapillary.

obtain the slope error. A digital micrometer device was used to measure the outline profile of the ellipsoidal moncapillary. According to the ratio between the outer (OD) and inner diameter (ID), the profile of inner surface could be obtained from the measured data.

The quality of the moncapillary was also tested by an X-ray source besides the optical measurement mentioned above. The X-ray test was a convincing and direct method to determine the quality of the optics. In the X-ray test experiment, we used a Cu X-ray tube whose spot size was 60 μm in diameter. An X-ray CCD camera with a 6.5-μm pixel size was used to align the optic device and obtain the image of the focal spot and far-field pattern of the moncapillary. In the test, the X-ray source was positioned 291.202 mm away from the ellipsoidal moncapillary center according to the parameters of Table 1. The moncapillary, CCD camera, and X-ray tube were each adjusted by five-dimensional stages.

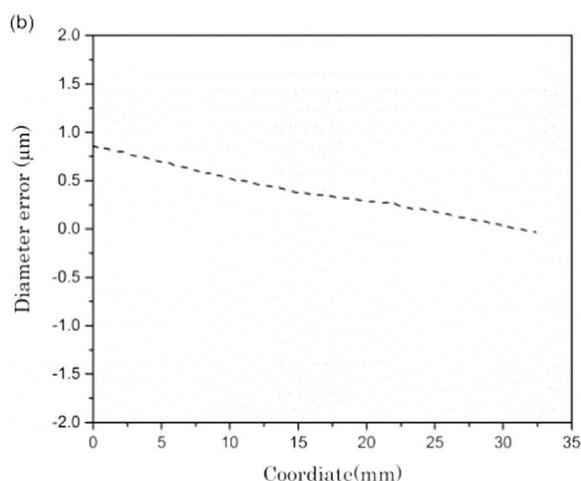
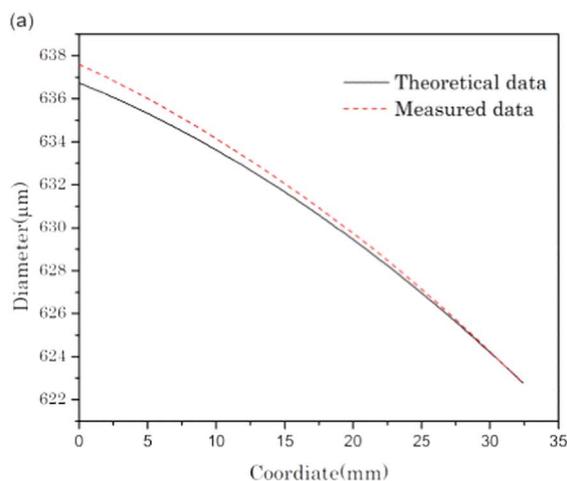


Fig. 2. (a)The optical test result of the inner diameter of the ellipsoidal moncapillary; (b) The inner diameter error.

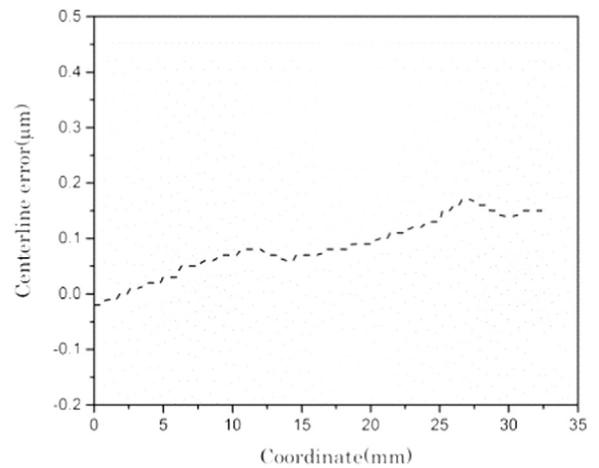


Fig. 3. The centerline straightness of the ellipsoidal moncapillary.

A beam stop in front of the moncapillary was used to block the X-rays that pass straight through the moncapillary without total reflection. The transmission efficiency of the moncapillary is defined as the ratio of the X-ray intensity transmitted through the moncapillary to the X-ray intensity at the effective entrance to the moncapillary. The transmission efficiency as a function of energy is important for all types of capillary X-ray optics. It can be measured with a pinhole and an energy dispersive detector [19]. The transmission efficiency of the moncapillary could be obtained by comparing the X-ray counts of the energy spectra from the moncapillary and a pinhole as following [19]:

$$\eta = \frac{N_{opt}}{N_{pin}} \times \frac{S_{pin}}{S_{opt}} \times \left[\frac{D_{opt}}{D_{pin}} \right]^2 \quad (1)$$

where N_{pin} is the collected counts from the pinhole at a certain energy, N_{opt} the collected counts from the optics at a certain energy, and S_{pin} the area of the pinhole entrance. S_{opt} is the area of the effective entrance to the moncapillary, which here is the area of a circular ring (Fig. 1). D_{opt} is the distance between the optics input and the X-ray source and D_{pin} is the distance between the pinhole and X-ray source.

The gain in power density of the moncapillary, which is the ratio between the power density at the focal spot with and without the moncapillary, could also be obtained by a similar measurement as following:

$$G = \frac{N_{opt}}{N_{pin}} \times \frac{S_{pin}}{S_{beam}} \times \left[\frac{D_{beam}}{D_{pin}} \right]^2 \quad (2)$$

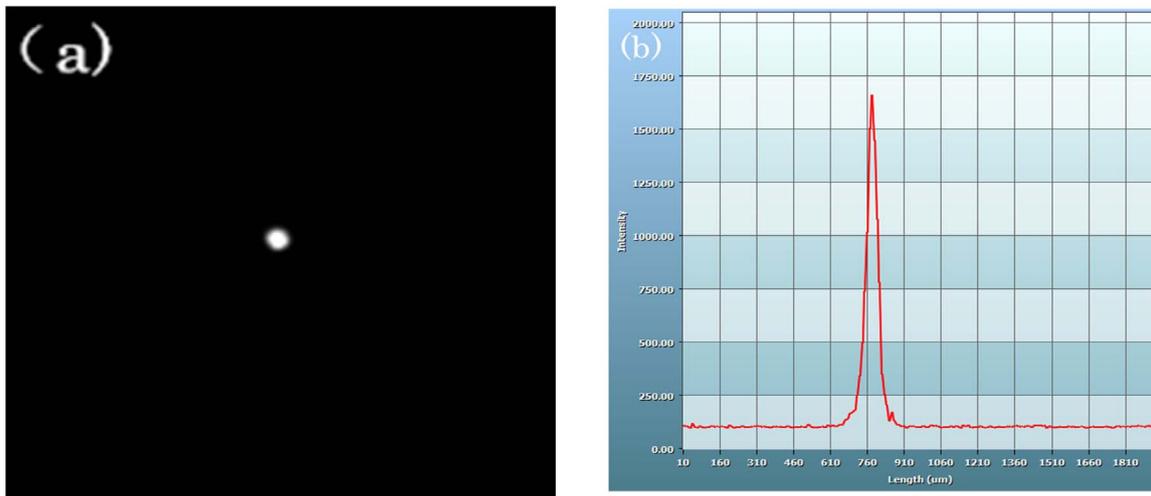


Fig. 4. (a) The image of the focal spot of the monocapillary; (b) The intensity profile of focal spot.

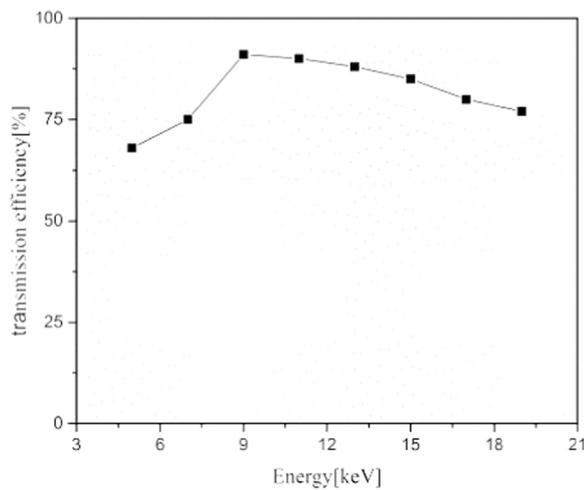


Fig. 5. Energy dependence of transmission efficiency for the monocapillary.

Here S_{beam} is the area of the focal spot of the monocapillary, S_{pin} the area of the pinhole entrance, D_{beam} the distance between the focal spot and the X-ray source, and D_{pin} the distance between the pinhole and the X-ray source.

3. Results and discussion

The quality of this optics was first established by an optical measurement. As shown in Fig. 2(a), the real profile of the inner surface of the monocapillary is close to the designed one. To provide a more detailed comparison, the diameter error between the theoretical and real shape of the monocapillary is shown in Fig. 2(b). The corresponding slope error of the diameter is 11 μ rad rms. The center-line error of the monocapillary is shown in Fig. 3 and the corresponding straightness error is 13 μ rad rms. According to the diameter and straightness errors, the total slope error of the monocapillary is $\sqrt{11^2 + 13^2} = 17$ μ rad rms. This total slope error of the monocapillary, which is smaller than the designed value of 50.0 μ rad, shows that our fabrication process meets the requirement of the X-ray nano-imaging technology.

In the X-ray test, we first measured the X-ray intensity reflected by the optics at different positions to determine the real focal spot position. The distance between the center of the monocapillary and the real focal spot was 206 mm. This value was a bit smaller than the theoretical focal spot distance, 208.798 mm. Fig. 4 shows the recorded image of the focal spot and the corresponding intensity profile of the monocapillary. The full width at the half maximum (FWHM) of the focal spot (Fig. 4(b)) is 50.0 μ m. This spot size is slightly bigger than the theoretical value of 43.2 μ m because the small slope error causes a blur at the focal spot. In addition to the focal spot size, the transmission

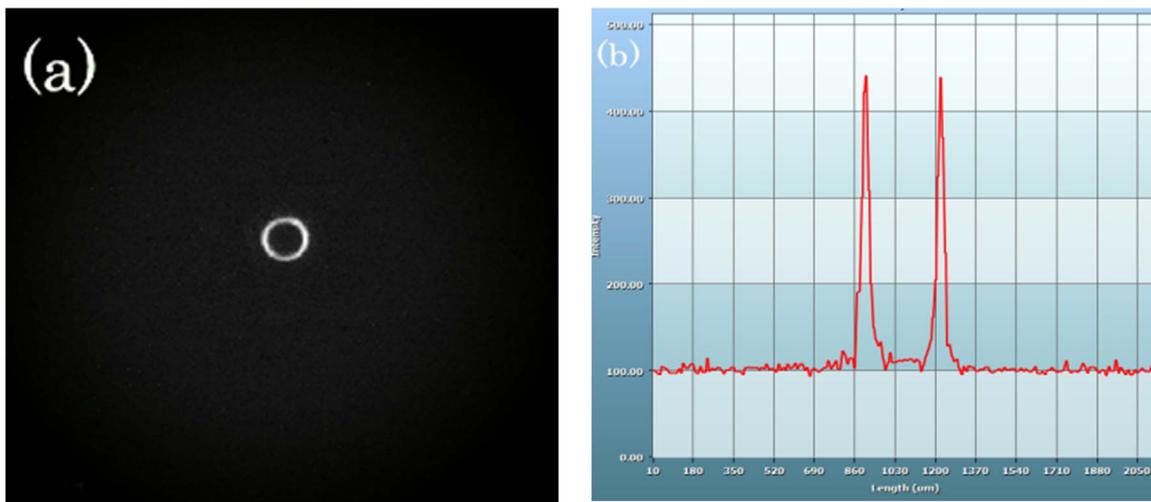


Fig. 6. (a) The far-field pattern of the monocapillary; (b) The intensity profile of the ring along the diameter.

efficiency and gain are another two important parameters to characterize the performance of optics. The energy dependence of the transmission efficiency of the monicapillary is shown in Fig. 5. As shown in Fig. 5, the transmission efficiency decreases at lower energies below about 9 keV. This can be explained by the increase of the absorption of photons with lower energies by the monicapillary wall. The decrease of transmission efficiency with the increasing energies above about 9 keV, which is shown in Fig. 5, is mainly caused by the decrease of the critical angle of total reflection with higher energies. The gain of the ellipsoidal monicapillary at the focal spot at 8.04 keV was 102, which was reached by the method mentioned above. Moreover, the far-field pattern recorded by the CCD camera at 90 mm from the focal spot of the monicapillary is shown in Fig. 6(a). This far-field pattern (Fig. 6) produced by the ellipsoidal monicapillary is helpful for evaluating the quality of the lens. As shown in Fig. 6(a), we can see that the ring is round. The intensity profile of the ring along the diameter is uniform as shown in Fig. 6(b), which satisfies the requirement of X-ray nano-imaging.

4. Conclusions

In this paper, we presented the fabrication and test of an ellipsoidal monicapillary condenser for X-ray nano-imaging. The slope error and the gain of this monicapillary were 17 μ rad and 102 at 8.04 keV, respectively. These parameters meet the requirement for X-ray nano-imaging. Moreover, this optics has potential applications in other fields, such as X-ray fluorescence, X-ray diffraction, and small angle scattering.

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